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PATENT  
8097-1003

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Takahuki SHIMAMUNE et al.

Conf. 2298

Application No. 10/527,801

Group 2892

Filed October 11, 2005

Examiner E. Ullah

PROCESS FOR PRODUCING HIGH-PURITY SILICON  
AND APPARATUS

AMENDMENT

Assistant Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

April 1, 2008

Sir:

In response to the Official Action mailed March 3, 2008, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 17 of this paper.